

A Review of Stereolithography: Processes and Systems

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Being the earliest form of additive manufacturing, stereolithography (SLA) fabricates 3D objects by selectively solidifying the liquid resin through a photopolymerization reaction. The ability to fabricate objects with high accuracy as well as a wide variety of materials brings much attention to stereolithography. Since its invention in the 1980s, SLA underwent four generations of major technological innovation over the past 40 years. These innovations have thus resulted in a diversified range of stereolithography systems with dramatically improved resolution, throughput, and materials selection for creating complex 3D objects and devices. In this paper, we review the four generations of stereolithography processes, which are scanning, projection, continuous and volumetric stereolithography. For each generation, representative stereolithography system configurations are also discussed in detail. In addition, other derivative technologies, such as scanning?projection, multi-material, and magnetically assisted stereolithography processes, are also included in this review.

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Review

A Review of Stereolithography: Processes and Systems

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Abstract: Being the earliest form of additive manufacturing, stereolithography (SLA) fabricates 3D objects by selectively solidifying the liquid resin through a photopolymerization reaction. The ability to fabricate objects with high accuracy as well as a wide variety of materials brings much attention to stereolithography. Since its invention in the 1980s, SLA underwent four generations of major technological innovation over the past 40 years. These innovations have thus resulted in a diversified range of stereolithography systems with dramatically improved resolution, throughput, and materials selection for creating complex 3D objects and devices. In this paper, we review the four generations of stereolithography processes, which are scanning, projection, continuous and volumetric stereolithography. For each generation, representative stereolithography system configurations are also discussed in detail. In addition, other derivative technologies, such as scanning–projection, multi-material, and magnetically assisted stereolithography processes, are also included in this review.

Keywords: additive manufacturing; stereolithography; scanning; projection; continuous

1. Introduction

Additive manufacturing (AM) technologies, commonly called three-dimensional (3D) printing, represent a set of processes that enable layer by layer fabrication of complex 3D structures with a wide range of materials. They have the capability to create advanced parts that display high levels of complexity in geometry, function and composition [1,2]. AM technologies have been combined with diverse areas including electronics [3,4], actuators [5,6], biomedical engineering [7] and sensors [8]. Specifically, three approaches of AM are widely used, which are extrusion-based 3D printing, selective laser sintering (SLS) or selective laser melting (SLM), and stereolithography [9]. Extrusion-based 3D printing allows for extruding polymers layer by layer to fabricate three-dimensional structures, which has been reported by plenty of papers, and fused deposition modeling (FDM) is one of the most typical and common extrusion-based 3D printing methods. The process of SLS or SLM is based on using powders that are converted into a continuous solid with ink-jetted binder or laser irradiation. The powders used in SLS or SLM vary from gypsum, which solidifies upon contact with a liquid binder, to plastic or metal particles capable of sintering (e.g., nylon and titanium) by localized heating by a high-powered laser. The approach of stereolithography is realized by a localized photopolymerization process, which is triggered by ultraviolet (UV) radiation and takes place within a bath containing liquid monomers, oligomers, and photoinitiators. Since stereolithography is versatile enough to generate a variety of highly complex 3D structures with high precision as well as acceptable cost, more and more materials [9] have been developed for a large range of applications, such as soft robotic actuators [10], sensors [11], medical implants [12], microfluidics devices [13] and energy storage components [14].

This article gives an overview of stereolithography on processes and systems. The background and process of stereolithography are given in this paper. The various stereolithography systems

based on different processes are categorized and emphasized. In addition, extension developments of stereolithography are introduced.

2. Stereolithography

2.1. Development

The first significant work associated with modern stereolithography AM systems emerged during the 1970s [15]. Swainson [16] presented a patent for a system in which 3D objects can be built by two intersecting radiation beams through either photochemically cross-linking or degrading polymers. Then, Herbert [17] introduced a system for building solid objects in a layer-by-layer method with photosensitive polymers. However, most people agree that modern stereolithography began with the work of CW Hull [18]. According to his idea (Figure 1), the 3D objects are formed layer by layer with photosensitive materials that can be cured by ultraviolet (UV) radiation. To date, stereolithography has received quite great progress and different approaches were developed for stereolithography systems. We here concluded and classified the reported approaches into four generations (Figure 2). In the early stage, the first generation stereolithography represented by Hull's work builds 3D products by scanning a laser beam over the liquid materials. To remove the limits of low efficiency, the second generation approach, also known as projection stereolithography, is able to cure each layer simultaneously by using photo mask technology. The third generation stereolithography was arisen in 2015 by Tumbleston et al. [19]. They devised a process of continuous liquid interface production (CLIP), which allows a much higher print speed than that of previous approaches to produce parts in minutes instead of hours. Most recently, a volumetric stereolithography that produces 3D objects with the unit of complex aperiodic 3D volumes on a time scale of seconds was reported [20–22], and it can be seen as the fourth generation. However, other stereolithography systems, such as color stereolithography [23] and thermal stereolithography [24], are not reviewed in this paper.

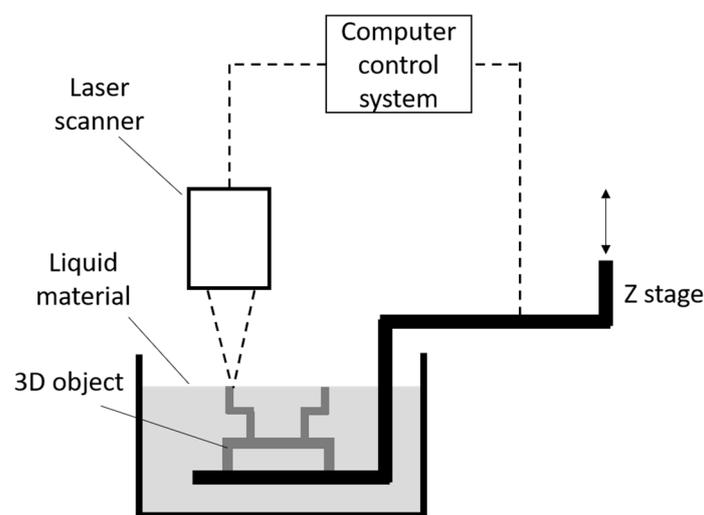


Figure 1. Hull's stereolithography system.

2.2. Process

The process of stereolithography (Figure 3a) starts with a standard tessellation language (STL) file, which now is the standard for every AM process [30]. By slicing the STL file, the 3D model is translated to 2D slices that contain the information of cross-sections [31,32]. According to these 2D slices, the physical model can be produced layer by layer. Figure 3b illustrates the structure of the STL file format. The 3D model of the STL format is represented with many small triangular facets.

Each triangular facet is described by the coordinates of three vertices and a unit vector pointing outside of the facet to indicate the normal direction [33,34].

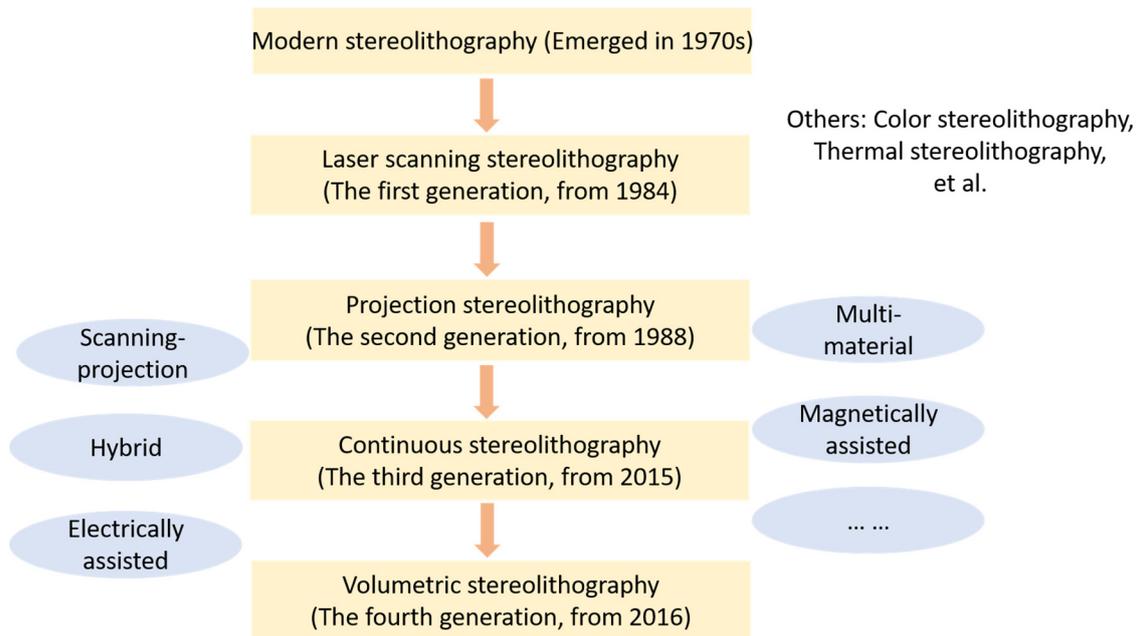


Figure 2. The overview of stereolithography [18,19,22–29]. As supplements, other kinds of processes and systems have also been provided (see Section 4), such as the scanning–projection process, hybrid stereolithography process, and multi-material process.

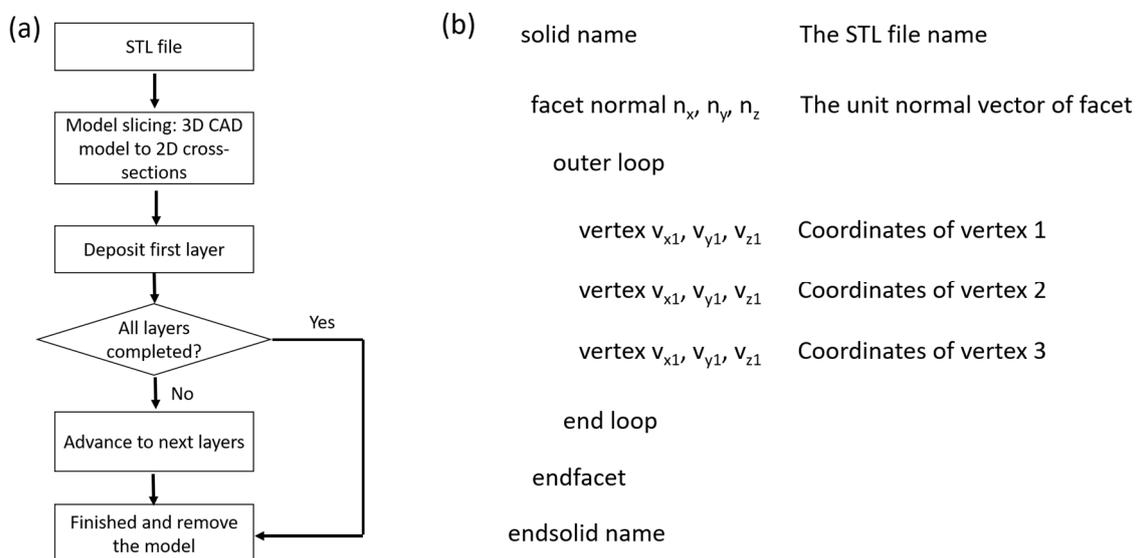


Figure 3. (a) The fabrication process of stereolithography. (b) The structure of the standard tessellation language (STL) file format.

The fundament of stereolithography is the curing reaction of resins, which is an exothermic polymerization process characterized by chemical cross-linking reactions [35,36]. The reaction is initiated by supplying the energy of UV light and there are two transitions during the curing reaction process: gelation and vitrification [35,37–42]. Gelation is a liquid-to-rubber transition that realizes a dramatic increase in viscosity. During this transition, both gel phase and sol phase coexist in the

system. Vitrification is a gradual, thermo-reversible process that leads to the transition from liquid or rubber resin to glassy solid resin [36,40,43–45].

3. Processes and Systems

Since modern stereolithography was proposed by Hull, it experienced four generations of technological innovation (Figure 2). Using different technologies, researchers have developed various kinds of physical systems for improving the performance of stereolithography. Benefiting from these systems, we are able to print sophisticated objects with several orders of magnitude in scale by using a variety of materials [9,46,47]. In this section, we will review the typical systems in each generation.

3.1. Laser Scanning Stereolithography

As the first generation, laser scanning stereolithography prints a 3D object by scanning a focused laser beam over the resin surface to cure the irradiated resin. To realize the scanning, some researchers used galvanometric mirrors to control the laser beam moving along the X–Y direction (Figure 4a) [48–50], while a motorized stage is adopted to switch the position for each layer. However, scanning with galvanometric mirrors results in defocusing of the light beam as well as optical errors [51–53]. Instead of galvanometric mirrors, using the X–Y translation stage with a fixed focused light beam can avoid these problems. During the printing, the focused laser point remains fixed on the resin and the X–Y translation stage is designed to move either all the optical system or the printing platform on which the object is printed. Figure 4b shows one such system, which is also known as constrained surface technique [54–58]. For this system, objects are produced below a transparent glass window since the fixed light beam focuses on resin through the window and the vector tracing of each layer is executed by motorized stages. The function of a transparent glass window is to push the liquid resin to avoid the fresh resin spreading on the already polymerized part of the object, which allows the layer thickness to be well controlled. However, polymerizing through a glass window causes a major drawback of the constrain-surface system, which is the adhesion of resin to the glass window. To overcome this problem, Zissi et al. [59] firstly described a scanning stereolithography system with a free surface technique in 1994 and Zhang et al. [60] also introduced their free-surface system with high resolution in 1998. The typical free-surface scanning stereolithography system is illustrated in Figure 4c. Like the constrain-surface system, motorized stages are also employed in the free-surface system to trace the contour profile of each layer of objects. The fixed UV light beam focuses on the resin surface and solidifies the curable resin to produce objects above the printing platform. Without adhesion issues, the free-surface stereolithography system shows excellent capability in fabricating microstructures [61–65]. In addition, another important laser scanning process, two-photon polymerization (2PP), is considered as a unique photopolymerization process [28,29,66–70]. It differs from conventional (single-photon) stereolithography by focusing femtosecond laser pulses to a very narrow spot in which the resin is polymerized via absorbing two photons simultaneously. Therefore, two photon polymerization has advantages in fabricating micro/nano-scale structures [71] with sub-100-nm resolution [72]. Figure 4d shows a typical setup of a 2PP system [73]. The most interesting part of 2PP is that it offers sub diffraction limit resolution for manufacturing fully 3D structures. Lithographic techniques with superior resolution, namely e-beam lithography, are limited to fabricate high aspect-ratio 2D structures. However, 2PP still shares the same common time-consuming issue as other scanning stereolithography methods since the fabrication of 3D structures is realized through the point-by-point addition of voxels.

3.2. Projection Stereolithography

In contrast to the scanning process, the second generation stereolithography can print each layer of objects simultaneously with a single exposure by projecting mask patterns onto the resin surface. The original ideal of photomask was proposed by Fudim in 1980s [26,27]. Fudim developed a system that illuminates a curable resin with UV radiation through masks and a piece of flat material

transparent to the radiation. Then, in the early 1990s, Pomerantz [75] introduced his photomask system to produce 3D models. The working process of his system can be concluded as: deposit a thin layer resin; illuminate the resin through a xerographically created mask that has a single cross section; remove the uncured resin; fill the regions vacated by the uncured resin; cure the rest of the layer; grind the surface to build a uniform layer; repeat these steps until the object is completed. However, this kind of photomask system requires a great number of masks and precise mask alignment, which consume a lot of cost and time.

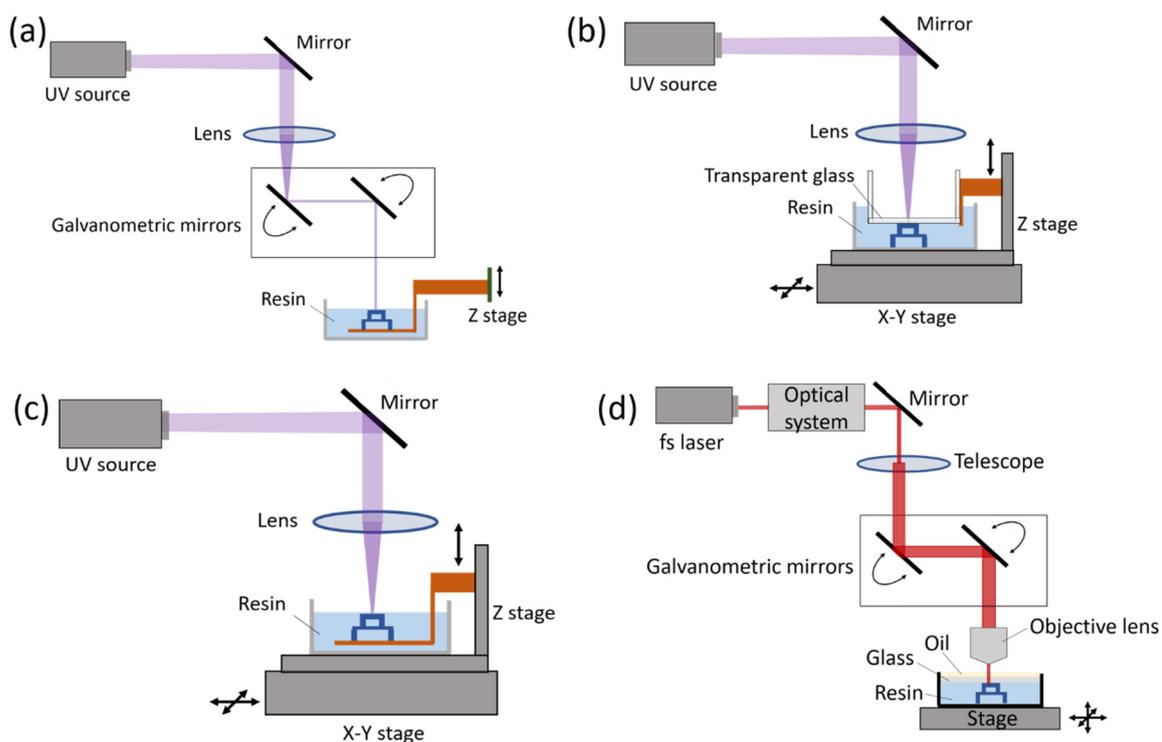


Figure 4. Scanning stereolithography processes. (a) Scanning stereolithography with dynamic light beam. (b) The constrain-surface system. (c) The free-surface system [74]. (d) A typical two-photon polymerization (2PP) system.

Replacing multiple mask sets with a dynamic mask is a solution to the mentioned drawbacks. Bertsch et al. [76] developed a projection stereolithography system by using a liquid crystal display (LCD) as dynamic mask. Each pixel of a LCD is a small cell that can be set either to its transparent or to its opaque state by changing the orientation of the molecules it contains. Thus, LCD can be used as a dynamic mask-generator in projection stereolithography systems. The LCD-based dynamic mask was further studied in projection stereolithography by researchers [77–84] in order to improve its performance. Although the LCD technique shows great superiority over previous processes, it has some intrinsic shortcomings. The large pixel size, very low transmission in UV and poor contrast seriously limit the further development of projection stereolithography systems.

The digital micromirror device (DMD) developed by Texas Instruments [85], which is widely used in video projection applications [86,87], has been adopted as a dynamic mask for projection stereolithography. The DMD is in fact an array of up to several millions of mirrors that can be controlled independently to generate mask patterns. Table 1 provides the comparison between LCD and DMD [88]. The first stereolithography system using DMD was reported by Bertsch et al. [89–91] while a light source with visible wavelengths was used in their system. C. Sun et al. [88] introduced their DMD-based stereolithography system in 2005. In their system, a UV light source and a UV curable resin of 1,6-hexanedioldiacrylate (HDDA) were used for the fabrication of complex 3D microstructures with the smallest feature of 0.6 μm . Figure 5 shows a typical top-down projection stereolithography

system. Due to the high efficiency, which only depends on the layer thickness and the required exposure time, and the excellent property of DMD, projection stereolithography using DMD as a dynamic mask has been widely used for micro manufacturing applications.

Table 1. Comparison between liquid crystal display (LCD) and digital micromirror device (DMD).

	LCD	DMD
UV compatibility	No	Yes
Modulation efficiency	12.5% (transmission)	88% (reflection)
Pitch size	26 $\mu\text{m} \times 24 \mu\text{m}$	14–17 μm
Pixel size	33 $\mu\text{m} \times 33 \mu\text{m}$	13–16.2 μm
Filling ratio	57%	91%
Contrast	100:1	350:1
Switching speed	20 ms	20 μs

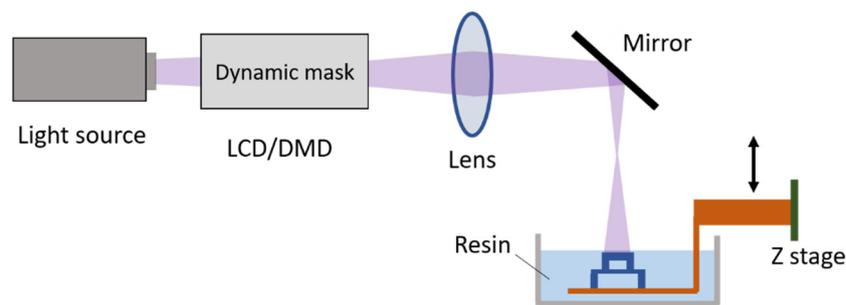


Figure 5. The top-down projection stereolithography system.

3.3. Continuous Stereolithography

Although projection stereolithography of the second generation makes it possible to cure each layer simultaneously with a single exposure, it is not a continuous manufacturing process from layer to layer. For the formation of each printed layer, three steps must be conducted sequentially: the first step is to expose resin to UV light, secondly the cured part needs to be mechanically moved either to separate from the surface of resin vat (for bottom-up systems) or to lower into the resin (for top-down systems) for resin renewal, and the third part is re-positioning [12,92,93]. Since each step takes several seconds, the printing speed is restricted to a few millimeters per hour. CLIP (Figure 6a) [19,94], achieved by creating a persistent liquid interface (dead zone) with an oxygen-permeable window below the UV image projection plane, is devised to print objects without stops from layer to layer. The oxygen-containing dead zone is able to inhibit the photopolymerization between the window and the polymerizing part, which allows the part to be continuously exposed while elevating. Thus, the latter two steps that existed in traditional stereolithography can be eliminated. By using the CLIP technique, the parts can be drawn out of the resin continuously at rates of hundreds of millimeters per hour. By integrating a side motion along the X axis between the resin tank and the Z platform to actively feed resin to the light exposure area, Y. Chen et al. [95,96] also presented their continuous stereolithography system. Differing from the passive resin feeding used in the CLIP technique, the resin recoating in Y Chen's system can be significantly accelerated by the side motion. Thus, the printing speed of continuous stereolithography is expected to be further improved. Due to strong competitive advantages, the CLIP technique has rapidly attracted a lot of attention, although it has only been a few years since it was first proposed [97,98].

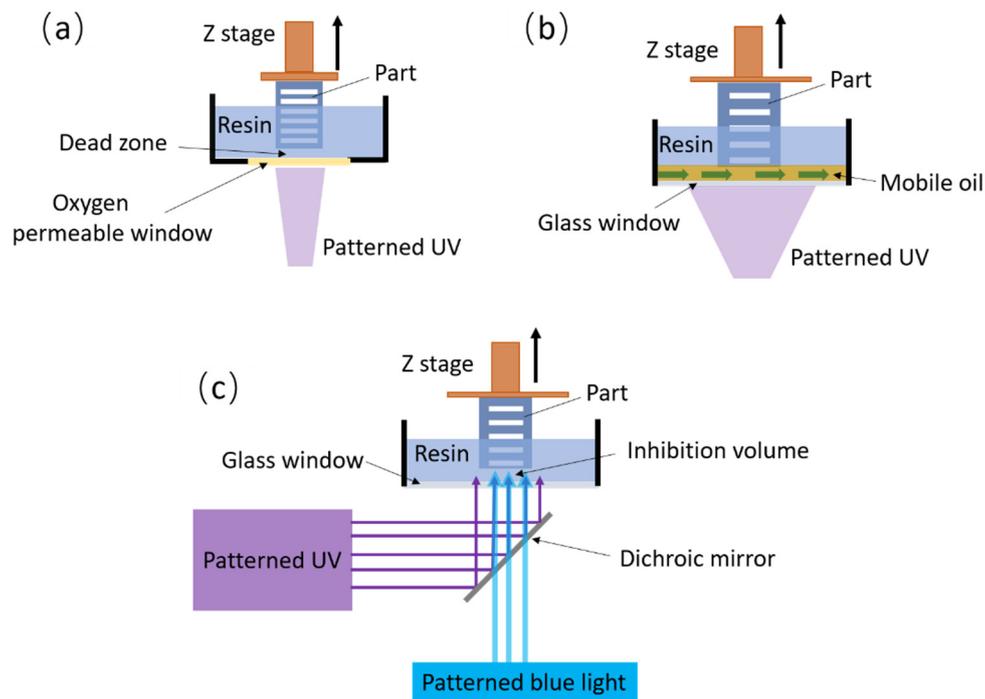


Figure 6. The continuous stereolithography processes. (a) Schematic diagram of the continuous liquid interface production (CLIP) process. (b) Schematic diagram of the high-area rapid printing (HARP) system. (c) The continuous stereolithography realized by using dual-wavelength irradiation.

In addition to CLIP, some researchers have reported their different continuous stereolithographic approaches. Chad A. Mirkin (Figure 6b) [99] reported a thermal controlled continuous stereolithographic approach that uses a mobile liquid interface to reduce the adhesive forces between the window and the curing objects. Since the mobile liquid interface (flowing immiscible fluorinated oil) can minimize interfacial adhesion at the build region and dissipate heat, the high-area rapid printing (HARP) can be realized by rapid print rates without thermal limitations. Timothy F. Scott et al. (Figure 6c) [100] demonstrated a dual-wavelength continuous stereolithography system, where one wavelength of light is used to inhibit the polymerization while a second wavelength of light initiates polymerization of the resin. By varying the intensity of two light sources, an inhibition region can be created between the window and the curing parts, eliminating adhesion and enabling continuous printing.

3.4. Volumetric Stereolithography

Distinguishing from previous stereolithography processes that fabricate structures layer by layer, volumetric stereolithography produces 3D objects with the formation of 3D volumes as a unit operation. Inspired by the holographic lithography, Maxim Shusteff et al. [20,22] first introduced volumetric 3D structures patterned as a single operation into 3D printing. They designed a volumetric stereolithography system (Figure 7a) in which the superposition of patterned optical fields from three orthogonal beams were projected into a photosensitive resin. By the compensation between each beam, volumetric 3D geometries can be formed in a single exposure from the superimposed profile. Timothy F. Scott's team further explored their dual-wavelength process to realize volumetric 3D printing (Figure 7b) [101]. By employing two perpendicular irradiation patterns at blue and near-UV wavelengths to independently effect either polymerization initiation or inhibition, the system allows the fabrication of objects by volumetric photopolymerization patterning in bulk resin. A promising volumetric additive manufacturing technique realized by tomographic reconstruction was separately proposed by Hayden K. Taylor et al. in 2019 [21] and Paul Delrot et al. in 2020 [102]. The tomographic volumetric

stereolithography is based on the simultaneous irradiation of an entire volume of photosensitive resin. As shown in Figure 7c,d, a cylindrical container of resin is set into rotation while it is being irradiated from the side with computed patterns of light. The light patterns computed by a Radon transform, similarly to tomography [103,104], are displayed in synchronization with the rotational movement of the resin container. After the resin has been illuminated from all angles by patterns, a three-dimensional distribution of accumulated light dose is created, causing the resin to locally reach its gelation threshold, thus the desired objects can be fabricated as a whole of volume (Figure 7e,f). Currently, the volumetric additive manufacturing has shown the potential to produce complex parts with a high throughput ($>10^5$ mm³ per hour) and a wide range of materials. In the foreseeable future, volumetric stereolithography is expected to be further developed in many aspects, such as resolution, process and physical system, and combined with various fields.

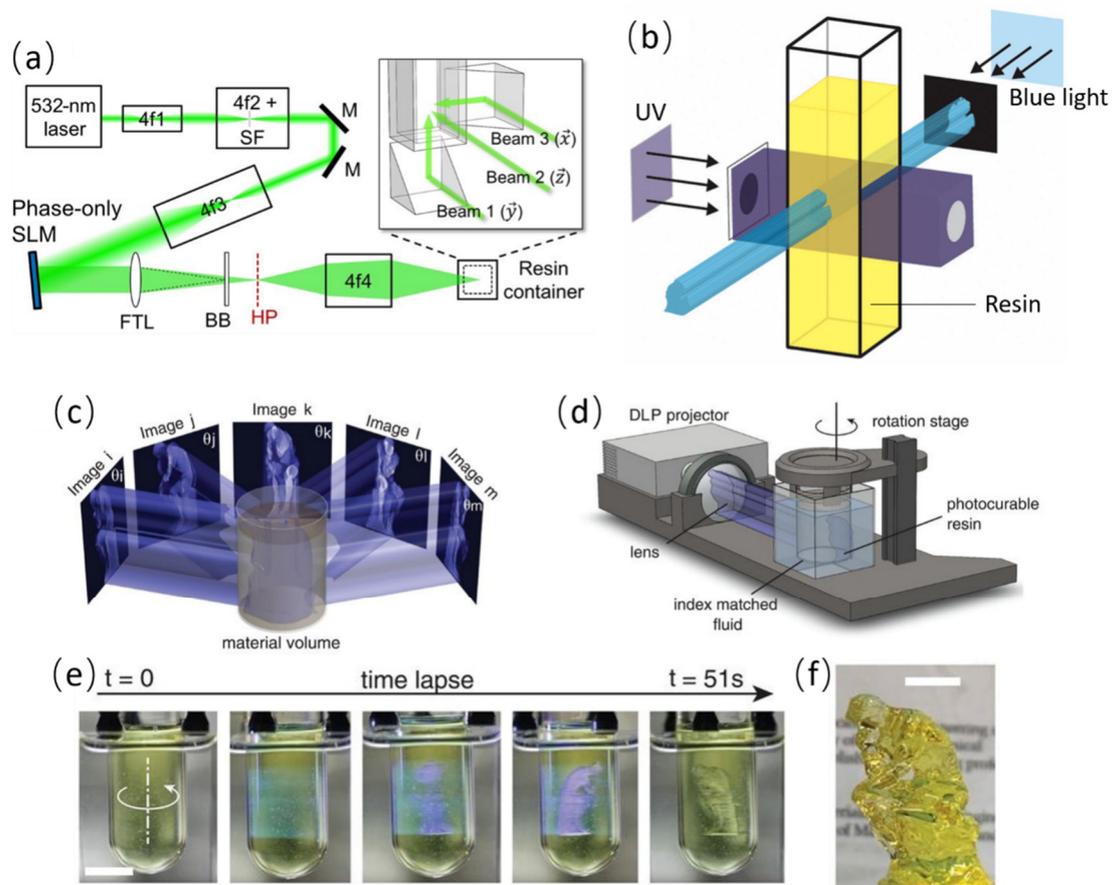


Figure 7. Volumetric stereolithography. (a) SLM, liquid crystal on silicon spatial light modulator; FTL, Fourier transform lens; BB, beam block to eliminate undiffracted light; HP, hologram plane; $4fN$, telescope lens pairs in the “4-f” configuration used for beam expansion or image relaying; $4f2$ incorporates a pinhole spatial filter (SF). The inset image details the configuration of 45° prism mirrors for directing image subcomponent beams at orthogonal directions into the resin volume [20]. (b) Schematic diagram of dual-wavelength volumetric polymerization. The polymerization process is inhibited by UV light and initiated by blue light [101]. (c) The concept of tomographic volumetric stereolithography: Patterned illumination from many directions delivers a computed 3D exposure dose to a photoresponsive material. (d) The tomographic volumetric stereolithography system. (e,f) show the printing process and a model printed by tomographic volumetric stereolithography. Scar bar: 10 mm [21].

3.5. Comparison

As stereolithography underwent four generations of major technological innovation, it provides flexible technique options for various applications. Table 2 compares four generations of stereolithography processes. By scanning a focused laser beam to cure the irradiated resin, scanning stereolithography has a large building area, which enables the capability to print large models [105]. Without the scanning process, projection stereolithography reduces or avoids the error caused by scanning motion and it is able to fabricate kinds of components with high accuracy [106,107]. Continuous stereolithography, which is developed based on projection stereolithography, significantly improves the yield efficiency by creating a deadzone where photopolymerization is inhibited between the window and the polymerizing part. The high output speed as well as high resolution benefit stereolithography technology by allowing precision parts to be printed in minutes. Since volumetric stereolithography builds geometries by 3D volumes, it has a high throughput and allows the processing of high viscous resins. The resolution of volumetric stereolithography is currently limited to the range of 80 to 300 μm [102]. It is expected that the volumetric stereolithography process will further improve the resolution and explore more applications in next few years.

Table 2. Comparison of four generations of stereolithography processes.

Stereolithography	Printing Speed	System Resolution	Printable Size	Light Source
Scanning	Scanning speed: hundreds to thousands of millimeters per second	A few microns (~100 nm for 2PP system)	From tens to hundreds of millimeters	UV light (Fs laser source for 2PP)
Projection	Tens of millimeters per hour	A few microns (typically greater than 5 microns)	Tens of millimeters	UV/Visible light
Continuous	Hundreds of millimeters per hour	A few microns (typically greater than 5 microns)	Tens of millimeters	UV/Visible light
Volumetric	Greater than 10^5 mm^3 per hour	80 ~ 300 microns	Tens of millimeters	UV light

4. Extensions

During the development of stereolithography processes from the first to the fourth generation, researchers also presented other different processes and systems. By combining the scanning process with projection, the scanning–projection stereolithography (Figure 8a) achieves a large printing area with a high resolution [108,109]. For example, Xiaoyu Zheng et al. [47] successfully fabricated 3D structures with disparate features spanning several orders of magnitude, from tens of nanometers to tens of centimeters, by scanning–projection stereolithography. To explore the advanced functional components, researchers employed stereolithography processes to build 3D objects with multiple materials [110–114]. By changing materials during the printing, the multi-material stereolithography is able to integrate multiple (usually two or three) materials into a 3D structure. Taking advantage of certain technologies, different kinds of innovative stereolithography systems are developed. Using magnetic fields to constrain magnetic particles, smart components with complicated and heterogeneous functions can be effectively produced by magnetically assisted stereolithography systems [115–117]. Similarly, by integrating with the electrical field and acoustical field, respectively, electrically assisted [118,119] and acoustically assisted [120] stereolithography systems were reported. Figure 8b–e show an electrically assisted stereolithography system and a printed object. To expand the manufacturing capacity, researchers integrated stereolithography with other AM technologies for specific applications. As an example, a hybrid AM system was developed by integrating stereolithography with direct-write technology to fabricate 3D structures with embedded electronic circuits [121]. In addition, the freeform stereolithography, usually achieved by using robotic devices and that aims to produce complex structures without additional auxiliary structures, was presented [122].

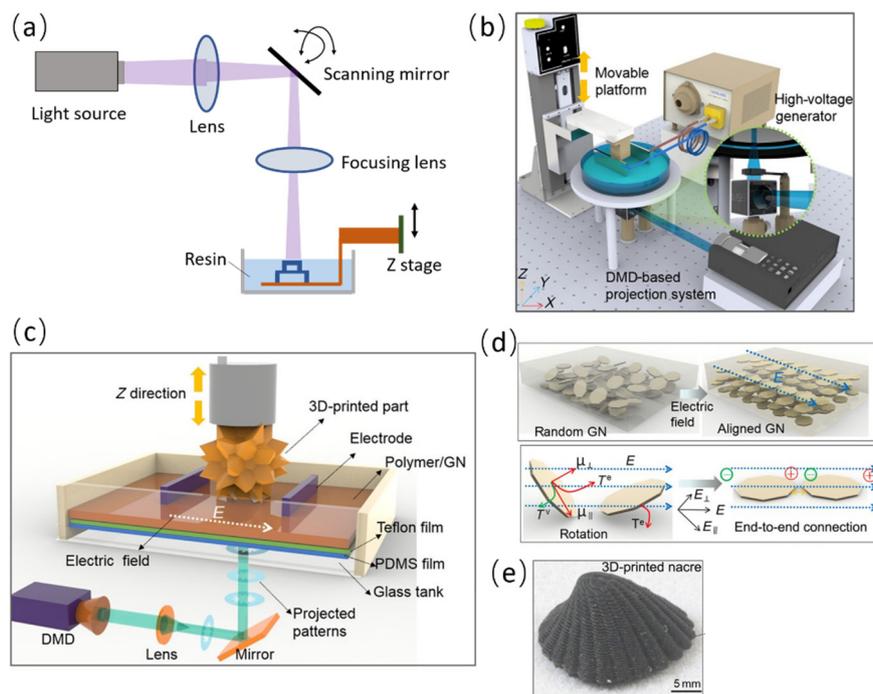


Figure 8. (a) The typical scanning–projection stereolithography system. (b) The setup of an electrically assisted stereolithography system. (c) Illustration of the bottom-up projection stereolithography with an electrical field. (d) The alignment of graphene nanoplatelets under the electric field and alignment mechanisms. (e) Electrically assisted 3D-printed nacre with graphene nanoplatelets [118].

5. Conclusions

Stereolithography is an additive manufacturing technique that fabricates 3D objects by selectively solidifying the resin through photopolymerization initiated by absorbing light energy. During the decades of development, various kinds of processes as well as systems of stereolithography are demonstrated, and this paper is the first to categorize stereolithography processes or systems into four generations in chronological order. From scanning to projection, stereolithography is able to build 3D objects by curing each layer simultaneously instead of tracking the contour profile of each layer, while the introduction of DMD brings high resolution and production rates to stereolithography. The continuous stereolithography further improves the print speed by removing the adhesion between curing parts and the window. Volumetric stereolithography presents a new idea in building objects that allows the formation of complex aperiodic 3D volumes as an unit operation. In addition, we also briefly included some other stereolithography systems in this review. Since this progress was made, stereolithography has already been widely applied to various fields. However, the pursuit of high resolution, high print speed and available size will be a meaningful topic for a long time in the future. Material is one of the major constraints for the development of stereolithography. It is necessary to develop stereolithography processes or systems for specific materials with desired properties. In addition, multi-material stereolithography still needs to be further studied on the physical system, available materials and the printing process. The freeform stereolithography, on which currently few studies have been made, makes it possible to fabricate objects with high flexibility and is expected to build complex 3D structures with additional assistance. It is expected that the freeform stereolithography will get more attention and make great progress.

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